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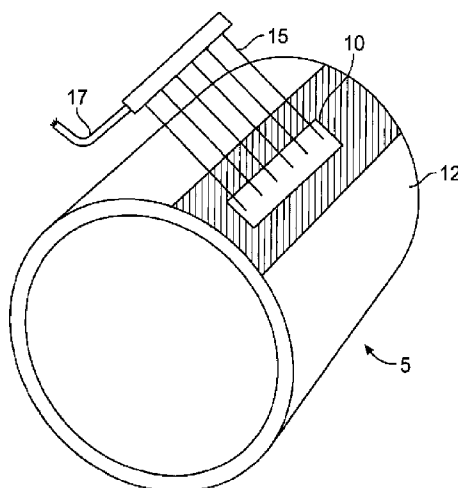


FIG. 1

(57) **Abstract:** The invention a piezoelectric self-cleaning apparatus, such as a chemical injection pump. The chemical injection pump is self-cleaning by employing either as an integral part or as an added part, a piezoelectric component that implosively cleans the pump head. This invention involves a liquid delivery system made of a liquid processing path and a piezoelectric actuator connected to or integral with said liquid processing path to enhance removal of unwanted solids from the liquid processing path or to maintain a blend, mix and/or integrity of a liquid chemical, wherein the liquid chemical does not precipitate particles, crystallize, separate or come out of solution.



Self Cleaning Piezoelectric Chemical Apparatus and Method of Use

FIELD OF THE INVENTION:

[0001] This invention relates to a piezoelectric self-cleaning apparatus designed to keep liquid processing path clear.

BACKGROUND OF THE INVENTION:

[0002] Mechanical pumps move chemicals through liquid processing path. These pumps can be adversely affected by clogging if the media(s) harden when the pump is off for too long a period or if particulates fall out of suspension due to various factors (such as pressure and temperature changes). Additionally, the pump
10 can be damaged by media blends separating while in the feed system, causing failure of the engineered chemical effects (such as in water or waste purification, oil/gas drilling, drug dispensing and food additives).

SUMMARY OF THE INVENTION:

[0003] The present invention relates to a piezoelectric self-cleaning apparatus,
15 such as a chemical injection pump. The chemical injection pump is self-cleaning by employing, either as an integral part or as an added part, a piezoelectric actuator that implosively cleans the pump. This is accomplished by exciting the piezoelectric actuator (in a range from Hz to MHz) at various frequencies specific to the chemical or blend of chemical in the apparatus.

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[0004] More specifically, this invention relates to a liquid delivery system providing a liquid processing path and a piezo-electric actuator connected to or integral with the liquid processing path to enhance removal of unwanted solids from the liquid processing path or to maintain a blend, mix and/or integrity of the chemical

so that it does not precipitate particles, crystallize, separate or come out of solution.

In this invention, the piezoelectric actuator can be a transducer for cleaning the liquid path or a piezo-material vibrating disc operating at selected frequencies to maintain a blend, mix and/or integrity of the chemical, so that it does not precipitate

5 particles, crystallize, separate or come out of solution.

[0005] Additionally this invention provides a method to remove unwanted solids from a liquid processing path to prevent the unwanted solids from clogging a liquid processing path in the pump head. This invention involves providing a piezo-material transducer within the inlet for a pump head, and also providing a modulated

10 DC voltage at a desired frequency and voltage level to the piezo-material transducer to generate acoustic waves in the liquid to remove unwanted solids from a liquid processing path, wherein the liquid is a chemical. The piezo-material transducer can be provided as an integral part of the inlet or connected to the inlet of a pump head.

15 [0006] This invention further provides a method to maintain a blend, mix and/or integrity of the chemical, so that it does not precipitate particles, crystallize, separate or come out of solution, by providing an at least one piezo-material vibrating disc located in the outlet of the pump head and providing a modulated DC voltage at a desired frequency and voltage level to the piezo-material vibrating disc

20 to generate acoustic waves to maintain a blend, mix and integrity of a chemical in solution, wherein the chemical does not precipitate particles, crystallize, separate or come out of solution. In the preferred embodiment the at least one piezo-material disc is a plurality of piezo-material discs.

[0007] This invention further provides a computer controlled apparatus to prevent unwanted solids from clogging a liquid processing path or to maintain a blend, mix and/or integrity of a liquid chemical, wherein the liquid chemical does not precipitate particles, crystallize, separate or come out of solution. This apparatus includes a piezoelectric actuator connected to or integral with the liquid processing path, a central processing unit programmed to control the delivery of DC voltage to the piezoelectric actuator at a desired frequency and voltage level to generate acoustic waves in the liquid, to remove unwanted solids from a liquid processing path or to maintain a blend, mix and/or integrity of the chemical so that it does not precipitate particles, crystallize, separate or come out of solution, wherein the liquid is a chemical; and means to transmit the modulated voltage to the piezoelectric actuator.

BRIEF DESCRIPTION OF THE SEVERAL VIEWS OF THE DRAWING:

[0008] For a fuller understanding of the nature and desired objects of the present invention, reference is made to the following detailed description taken in conjunction with the accompanying drawing figures.

[0009] **FIG. 1** shows a perspective view of a vibrating actuator of a piezo-material transducer.

[0010] **FIG. 2** shows a perspective view of a vibrating disc of a piezo-material.

[0011] **FIG. 3** shows a perspective view of self-cleaning chemical apparatus such as a metering pump.

[0012] **FIG. 4** shows a block diagram of this invention.

[0013] **FIG. 5** shows a logic diagram of this invention.

DETAILED DESCRIPTION OF THE INVENTION:

[0014] The present invention may be understood more readily by reference to the following detailed description of the invention. It is to be understood that this invention is not limited to the specific devices, methods, conditions or parameters
5 described herein, and that the terminology used herein is for the purpose of describing particular embodiments by way of example only and is not intended to be limiting of the Claimed invention. Also, as used in the specification including the appended Claims, the singular forms "a," "an," and "the" include the plural, and reference to a particular numerical value includes at least that particular value,
10 unless the context clearly dictates otherwise. Ranges may be expressed herein as from "about" or "approximately" one particular value and/or to "about" or "approximately" another particular value. When such a range is expressed, another embodiment includes from the one particular value and/or to the other particular value. Similarly, when values are expressed as approximations, by use of the
15 antecedent "about," it will be understood that the particular value forms another embodiment.

[0015] The present invention relates to a piezoelectric self-cleaning apparatus, such as a chemical injection pump. The chemical injection pump is self-cleaning by employing either as an integral part or as an added part, a piezoelectric component
20 that implosively cleans the pump head. Various advanced materials can be used for this purpose including, for example, lead zirconate titanate (PZT), polyvinylidene difluoride (PVDF), and Lithium Niobate. These piezoelectric materials can be used to make pump parts and assemblies that form part of the pump head and can either be driven between hertz to megahertz range or be electronically resonated in the

kilohertz frequency range. These parts can be either automatically or periodically actuated for implosive cleaning of unwanted materials that form as a residue in the pump. Additionally the piezoelectric parts can be electronically driven at various frequencies specific to the chemical or blend of chemicals in the apparatus, such as a pump, to maintain particles or a specific chemical blend from precipitating or separating out of an emulsion while in the apparatus.

[0016] A piezo electric transducer is a transducer composed of a piezo-electric material, such as a crystal, that converts an electrical signal to a mechanical or acoustic signal and vice versa. In this invention, a piezo-material component integral with an inlet for a pump head functions as a transducer. The piezo-material is actuated by providing a modulated DC voltage at the desired frequency and voltage level, which is sufficient to generate acoustic waves in the liquid to remove unwanted solids from a liquid processing path. The desired frequency and voltage values are selected based on the specific application, such as cleaning or chemical mixing. Power supplies for the piezo-materials can range from power densities up to 10 w/sq.cm and frequencies up to 10 MHz depending on the applications of interest. Power supplies are standard commercial systems that would be known to those that understand the art.

[0017] The term driving frequency means the frequency of the driving force. The driving force is an external force and in this invention this is the modulated DC voltage. The piezo material voltage is defined as the voltage required to actuate the piezo material. Driving frequency is the frequency of the driving force. The driving force is an external force applied to the oscillator. Voltage and frequency combination is generated using industry standard piezoelectric power supplies.

[0018] The piezoelectric self-cleaning apparatus can be used with a variety of chemical, some examples include: sodium hypochlorite, aluminum sulfate, sulphuric acid and caustic polymer phosphate. Sodium hypochlorite is used in water purification.

5 [0019] The frequency ranges contemplated by this invention include: sub-Khz frequency range where resonant effects from piezo material geometries can be used, 20 to 40 Khz frequency range to provide relatively fast cleaning (minutes) for large and simple geometric surfaces, 40 -70 kilohertz frequency range surfaces with complex geometries, 70 Khz to 10 MHz frequency range for specialty operations
10 such as the fine, gentle cleaning of surfaces and mixing of chemicals. In one embodiment, the piezo-material transducer 5 is use for cleaning process with 40 Khz or less frequencies.

[0020] **FIGS. 1 and 2** show individual piezo-ceramic components that are part(s) of an automatic self-clean and vibrating chemical metering pump shown in
15 **FIG. 3**. More specifically, **FIG. 1** shows piezo-material transducer 5 made of a piezo-material in the form of a cylinder; however, any geometrical form that provides the necessary vibrations can be used in this invention. In the preferred embodiment, this piezo-material is lead zirconate titanate (a piezoelectric ceramic material); however, any piezo-material can be selected based on the frequency requirements.

20 [0021] In this embodiment, lead zirconate titanate is coated with a protective coating preferably, titanium oxide (or any other oxide or nitride) coating which allows the piezo-material transducer 5 to be chemically inert to chemical being pumped such as sodium hypo- chlorite in all concentrations (or other aggressive chemicals),

as known to one skilled in the art. See Bharat Shushan Springer Handbook of Nanotechnology, Volume 2 (hereby specifically incorporated by reference).

[0022] In the embodiment shown in **FIG. 1**, a coated piezo-material, preferably lead zirconate titanate, is formed into a piezo-material transducer **5** via blending material(s), pressing, heating and poling. The piezo-material transducer **5** has a connection block **10** on the outer wall **12** of the piezo-material transducer **5** for soldering directly on to the surface of the piezo-material actuator **5** a plurality of electrical connectors **15** and electrical leads, **17** as necessary to apply DC current to the piezo-material transducer **5** to achieve the current density necessary to clean by sweeping at and individually through frequencies in the kilohertz range, such as 40KHZ, at 60KHZ and 80KHZ. +/- 10% sweep at each of the main cleaning frequencies.

[0023] The piezo-material transducer **5** can be integral or an add-on to a module of a chemical pump or the chemical pump itself with its own micro-controller with an embedded software program that based upon time and control of frequencies will allow the sweep and duration of the cleaning frequency based upon the "standard" known ultrasonic KHZs used, but also have a sub-routine around each standard frequency that sweeps through +/- 5% either side of the frequency.

[0024] **FIG. 2** shows a piezo-material vibrating disc **20**. Disc **20**, in the preferred embodiment, is deployed as a plurality of discs. The piezo-material vibrating disc **20** can be tuned to the unique material and material blends characteristic frequencies. In the preferred embodiment, this piezo-material is lead zirconate titanate (a piezoelectric ceramic material); however, any piezo-material can be selected based on frequency requirements. In this embodiment, lead zirconate

titanate is coated with a protective coating preferably, titanium oxide (or any other oxide or nitride) coating which allow disc **20** to be chemically inert to chemical being pumped such as sodium hypo- chlorite in all concentrations (or other aggressive chemicals).

5 [0025] **FIG. 2** shows that a piezo-material vibrating disc **20** has a connection block **21** on the outer wall **22** of the piezo-material vibrating disc **20** for soldering directly on to the surface of the piezo-material vibrating disc **20** a plurality of electrical connectors **25** and electrical leads, **27** as necessary to apply a modulated DC voltage to the piezo-material vibrating disc **20**.

10 [0026] In one embodiment, the piezo-material vibrating disc **20** will also have a connection block **21** made of a silver/ceramic composite pad for wire attachment **25** and **27** to drive the piezo-material vibrating disc **20** to vibrate in this embodiment at megahertz frequencies (high frequency) specific for a chemical such as the common sodium hypochlorite concentrations (5 to 12% sodium hypo solutions)
15 provided for water purification. The intent for driving at high frequency for the specific chemical (or concentration of chemical) is to generate acoustic waves in a given chemical or concentration to as to maintain an ideal blend, mix and/or integrity of the chemical so that it does not precipitate particles, crystallize, separate or otherwise degrade the intended effect of the pumped chemical.

20 [0027] **FIG. 3** is the embodiment of the invention showing integration of the piezo-material transducer **5** in the inlet **32** and a plurality of piezo-material vibrating discs **20** in the outlet **35** of the pump head **30** of a representative reciprocating diaphragm chemical dosing metering apparatus **1** forming a liquid processing path where the liquid flows in the inlet **32** and out the outlet **35**.

[0028] In this embodiment, piezo-material vibrating disc **20** will also have a connection block **21** made of a silver/ceramic composite pad for wire attachment **25** and **27** to power the piezo-material vibrating disc **20** to resonate in that piezo-material vibrating disc **20** has a connection block **21** on the outer wall **22** of the piezo-material vibrating disc **20** for soldering directly on to the surface of the piezo-material vibrating disc **20** a plurality of electrical connectors **25** and electrical leads, **27** as necessary to apply voltage to the piezo-material vibrating disc **20**, connected to a microprocessor based programmable control **40**. The piezo-material actuator **5** has a connection block **10** on the outer wall **12** of the piezo-material transducer **5** for soldering directly on to the surface of the piezo-material transducer **5** a plurality of electrical connectors **15** and electrical leads **17** as necessary to apply modulated DC voltage to the piezo-material actuator **5** to achieve the current density and frequency necessary to drive the piezo-material actuator **5** to ultrasonically clean the pump head **30**.

[0029] The vibrating frequencies of the plurality of piezo-material vibrating discs **20** will be at higher frequencies than the piezo-material transducer **5**. These higher frequencies will maintain fluid blends a wetted pump head **30** surfaces. These higher frequencies are actuated and controlled via the microprocessor **40** once an hour for a selectable and programmable duration, in this embodiment. The purpose here is to 'kiss' the wetted material walls with a much gentler high frequency to keep the all boundary layers vibrating and maintain the chemical in solution.

[0030] The piezo-material transducer **5** and the array of piezo-material vibrating discs **20** can be made integrally with the pump head **30**. The main pump body **31** as shown, is representative of all chemical bodies in general (which have

many different physical shapes/size). The pump head **30** is a part of the main pump body **31** but because the fluids pumped pass through the pump head, **30** the main pump body **31** encompasses it and the pump motor (or prime mover) (Not shown).

[0031] Alternatively, the piezo-material transducer **5** and piezo-material vibrating discs **20** could be a separate assembly manufactured to be an add on for all the chemical metering pumps installed in the market place or as an add on for all chemical metering pumps built without self-cleaning ultrasonics and or specific chemical or chemical concentrations resonance.

[0032] A microprocessor **40** based programmable control allows for various 'blocks' of frequencies to be powered, controlled for optimum cleaning and vibrating 'tuning' effect and also to sweep through a range of frequencies for both cleaning the pump head **30** and/or vibrating the plurality of discs **20** for many different chemical or blends of chemicals. A microprocessor **40** based programmable control provides the ability to tune to and sweep through ideal cleaning frequencies and to tune to the desired frequencies of individual chemicals or blends of chemicals. This is accomplished using the same micro-controller **40** with sub-routines controlling specific (and preset selectable or user commanded) vibrating frequencies.

[0033] Now referring to **FIGS. 4 and 5**, a block and logic diagram of the invention is shown. Serial commands input are received from a remote computer **39** to the microprocessor **40**. The microprocessor **40** is connected to the power stage **42** for a plurality of piezo-material vibrating discs **20** or in the alternative an ultrasonic piezo-material actuator **5**. The power stage **42** is connected to the plurality of piezo-material vibrating discs **20**. The power stage **42** is connected to an ultrasonic piezo-material actuator **5**. The plurality of piezo-material vibrating discs **20** are modulated

by voltages nominally from 50 to 150 volts DC. The ultrasonic piezo-material actuator **5** is modulated by a FM (frequency). The modulation can be in the form of varying DC voltage or frequency modulation. This can be achieved by method know to one skilled in the art but for illustration a switch selection frequency **47** is
5 connected to the microprocessor **40**.

[0034] Not referring to **FIG. 5**, in an exemplary embodiment, a cleaning period is selected from serial command or manual selection **53**, then the initial cleaning period, the media type and maintenance interval is selected **51**. The pump **31** is started **50**. The cleaning cycle **52** is started for a selected period. If the pump **31** is
10 not running after the initial cleaning cycle **54** then the pump **31** is stopped **57**. If the pump **31** is running after the initial cleaning cycle **54** then the pump **31** is not stopped until the run media maintenance interval **56**. If the pump **31** stops **57**, then if the initial cleaning cycle **58** is not off continues cleaning until the cycle is finished **59**. If the initial cleaning cycle **58** is off then it is determined if the head is
15 wetted **60**; if not then the pump **31** is stopped **61**, if yes then the cleaning cycle is pulsed **62**. After this step, the pump **31** is stopped **63**.

[0035] Example 1-- A $\frac{3}{4}$ " chlorinated polyvinyl chloride pipe segment with scaling due to Sodium Hypochlorite, was exposed to 40 KHz frequency for 1-2 minutes using an 80 W power supply to successfully clean the pipe. A piezoelectric
20 material (PZT) was used to generate the 40 KHz frequency in the system. Higher power can be used for larger pipe diameters and higher frequencies can be used for gentler cleaning or mixing of chemical blends within the pipe.

[0036] These and other aspects, features and advantages of the invention will be understood with reference to the detailed description herein, and will be realized

by means of the various elements and combinations particularly pointed out in. the
appended Claims. It is to be understood that both the foregoing general description
and the following detailed description of the invention are exemplary and explanatory
of preferred embodiments of the invention, and are not restrictive of the invention, as

5 Claimed.

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In the Claims:

1. A liquid delivery system comprising: a liquid processing path and a piezoelectric actuator connected to or integral with said liquid processing path to enhance removal of unwanted solids from the liquid processing path or to maintain a blend, mix and/or integrity of a liquid chemical, wherein said liquid chemical does not precipitate particles, crystallize, separate or come out of solution.
2. The system of Claim 1 wherein said piezoelectric actuator is a transducer.
3. The system of Claim 2 wherein said liquid processing path includes a pump head, and said piezoelectric actuator is a transducer and said transducer is integral with an inlet of said pump head.
4. The system of Claim 1 wherein said piezoelectric actuator is comprised of at least one piezo-material vibrating disc.
5. The system of Claim 4 wherein said liquid processing path includes a pump head and said piezo-electric actuator and said at least one piezo-material vibrating disc is integral with an outlet of said pump head.
6. A method to remove unwanted solids from a liquid processing path to prevent the unwanted solids from clogging a liquid processing path, including a pump head comprising:
providing a piezo-material transducer integral with or attached to an inlet of a pump head, and
providing a modulated DC voltage at a desired frequency and voltage level to the piezo-material transducer to generate acoustic waves in the liquid to remove unwanted solids from a liquid processing path, wherein said liquid is a chemical.
7. The method of Claim 6 wherein the voltage is DC.

8. The method of Claim 6 wherein the frequency of said current ranges from 20 to 40 Khz

9. The method of Claim 6 wherein in the frequency of said current ranges from 40 to 70 Khz.

5 10. The method of Claim 6 further comprising providing a plurality of piezo-material vibrating discs integral with or attached thereto to an outlet of the pump head, and providing a modulated DC voltage at a desired frequency and voltage level to the plurality of piezo-material vibrating discs to generate acoustic waves to maintain a blend, mix and integrity of a chemical in solution, wherein said chemical
10 does not precipitate particles, crystallize, separate or come out of solution.

11. The method of Claim 10 wherein in the frequency of said current ranges from 70 to 100 Mhz.

12. A method to maintain a blend, mix and/or integrity of a liquid chemical, wherein said liquid chemical does not precipitate particles, crystallize, separate or
15 come out of solution comprising:

providing a plurality of vibrating piezo-material discs integral with an outlet for a pump head, and providing a modulated DC voltage at a desired frequency and voltage level to the plurality of piezo-material vibrating discs to generate acoustic waves to maintain a blend, mix and integrity of a chemical in solution, wherein said
20 chemical does not precipitate particles, crystallize, separate or come out of solution.

13. The method of Claim 12 wherein in the frequency of said current ranges from 40 to 70 Khz.

14. The method of Claim 12 wherein in the frequency of said current ranges from 70 to 100 Mhz.

15. A computer controlled apparatus to prevent unwanted solids from clogging a liquid processing path or to maintain a blend, mix and/or integrity of a liquid chemical, wherein said liquid chemical does not precipitate particles, crystallize, separate or come out of solution comprising:

- 5 a piezoelectric actuator connected to or integral with said liquid processing path;
a central processing unit programmed to control the delivery of DC voltage to the piezoelectric actuator at a desired frequency and voltage level to generate acoustic waves in the liquid, to remove unwanted solids from a liquid processing path, or to maintain a blend, mix and/or integrity of a liquid chemical, wherein said liquid
10 chemical does not precipitate particles, crystallize, separate or come out of solution, wherein said liquid is a chemical;

and

means to transmit said modulated voltage to the piezoelectric actuator.

16. The apparatus of Claim 15 wherein said piezoelectric actuator is a transducer.

- 15 17. The apparatus of Claim 15 wherein said liquid processing path includes a pump head, and said actuator is a transducer and said transducer is integral with an inlet of said pump head.

18. The apparatus of Claim 15 wherein said piezoelectric actuator is comprised of a plurality of vibrating piezo material discs.

- 20 19. The apparatus of Claim 18 wherein in said plurality of piezo material vibrating discs are integral with in an outlet of the pump head.

20. The apparatus of Claim 18 wherein the plurality of piezo vibrating discs are connected with the outlet of said pump head.

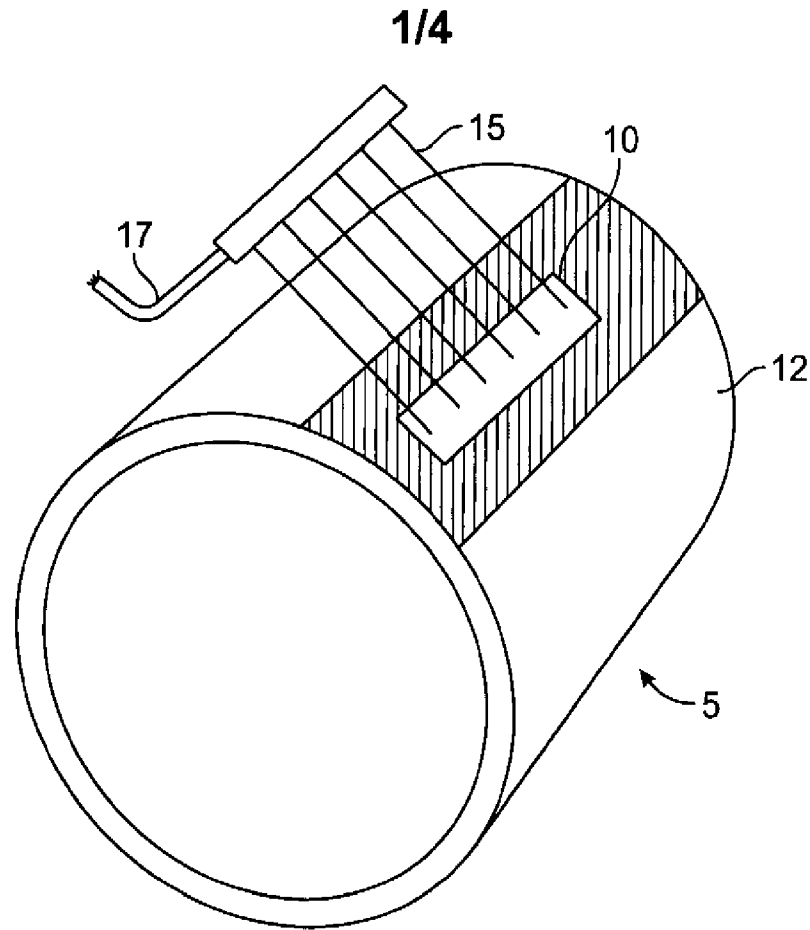


FIG. 1

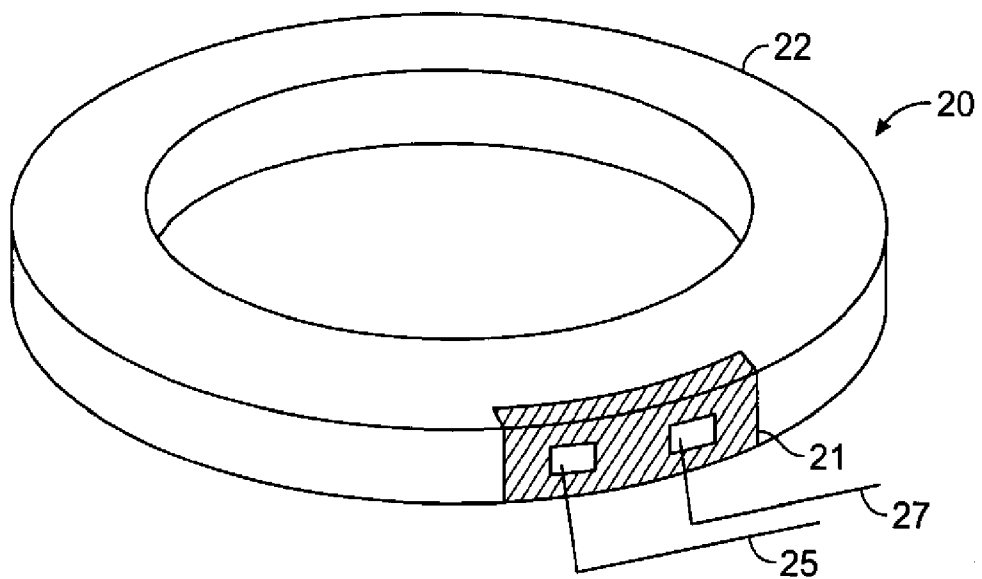


FIG. 2

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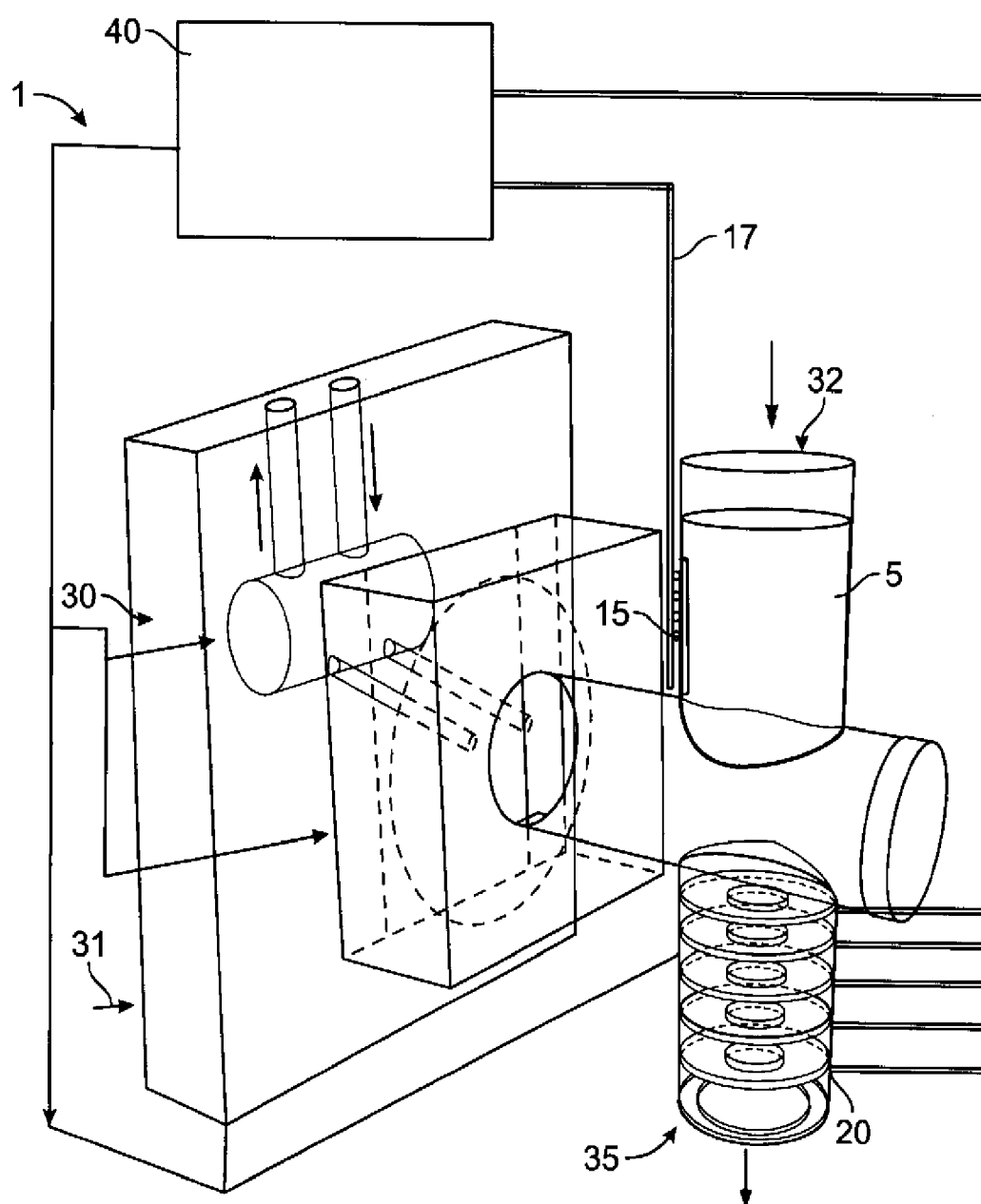


FIG. 3

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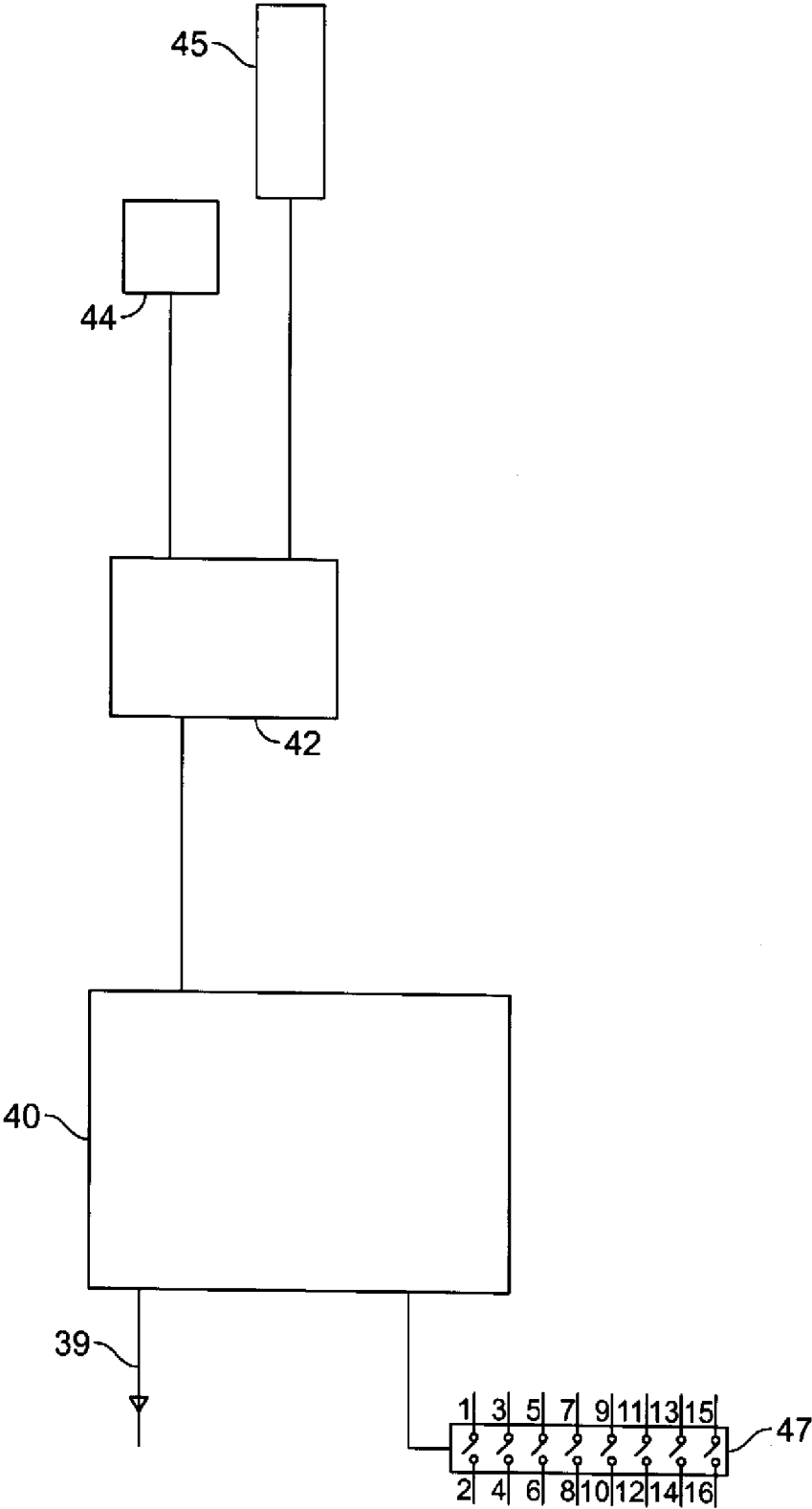


FIG. 4

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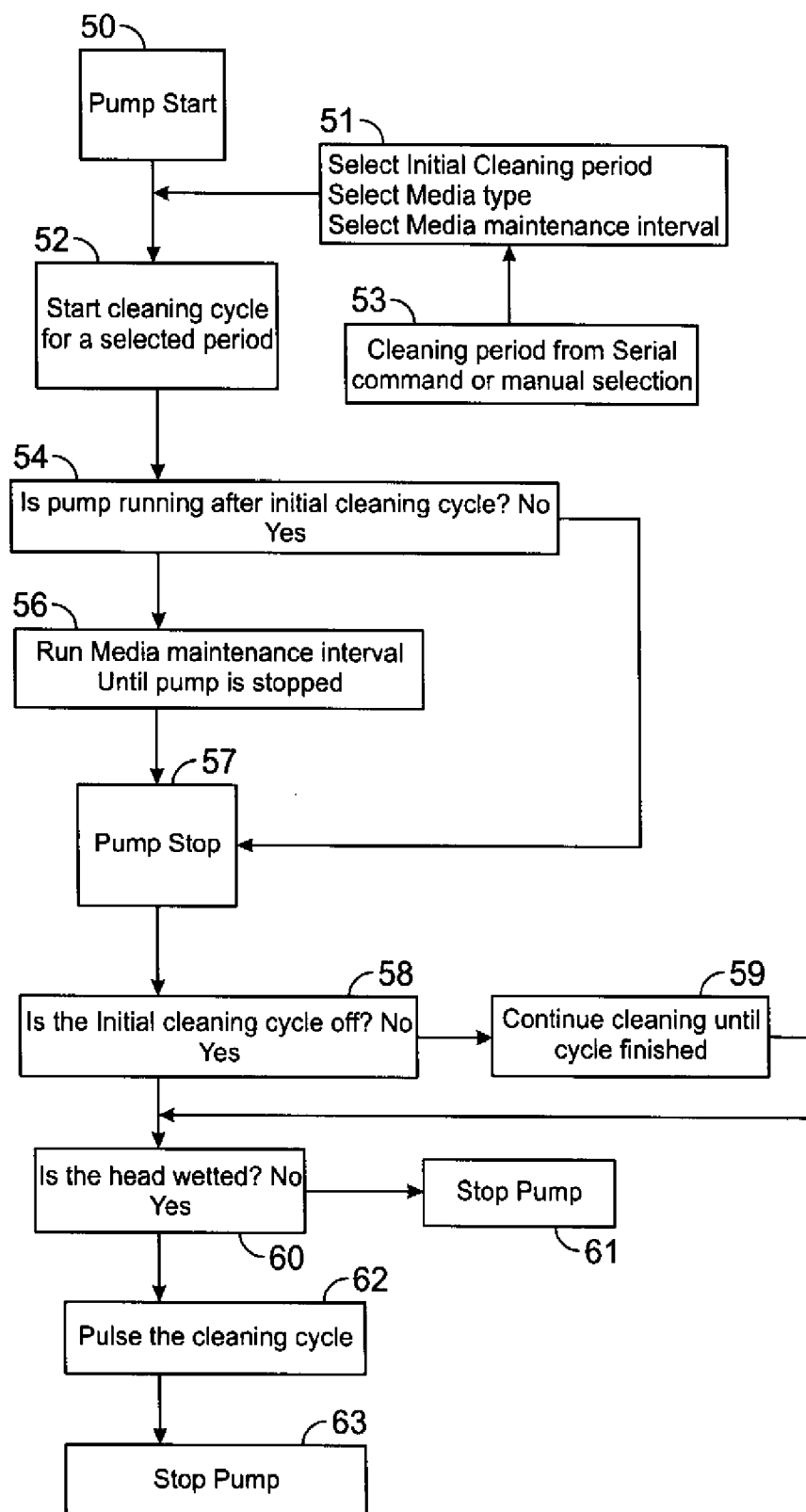


FIG. 5